

RESONANT TUNNELING DIODES

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ECE 3080 – Semiconductor Devices

Overview



- Introduction
- Device Operation
- Performance
- Applications
- Conclusion

Introduction



- Tunnel Diodes

- ▣ Very fast switching for low power, high frequency applications

- Numerous Variations

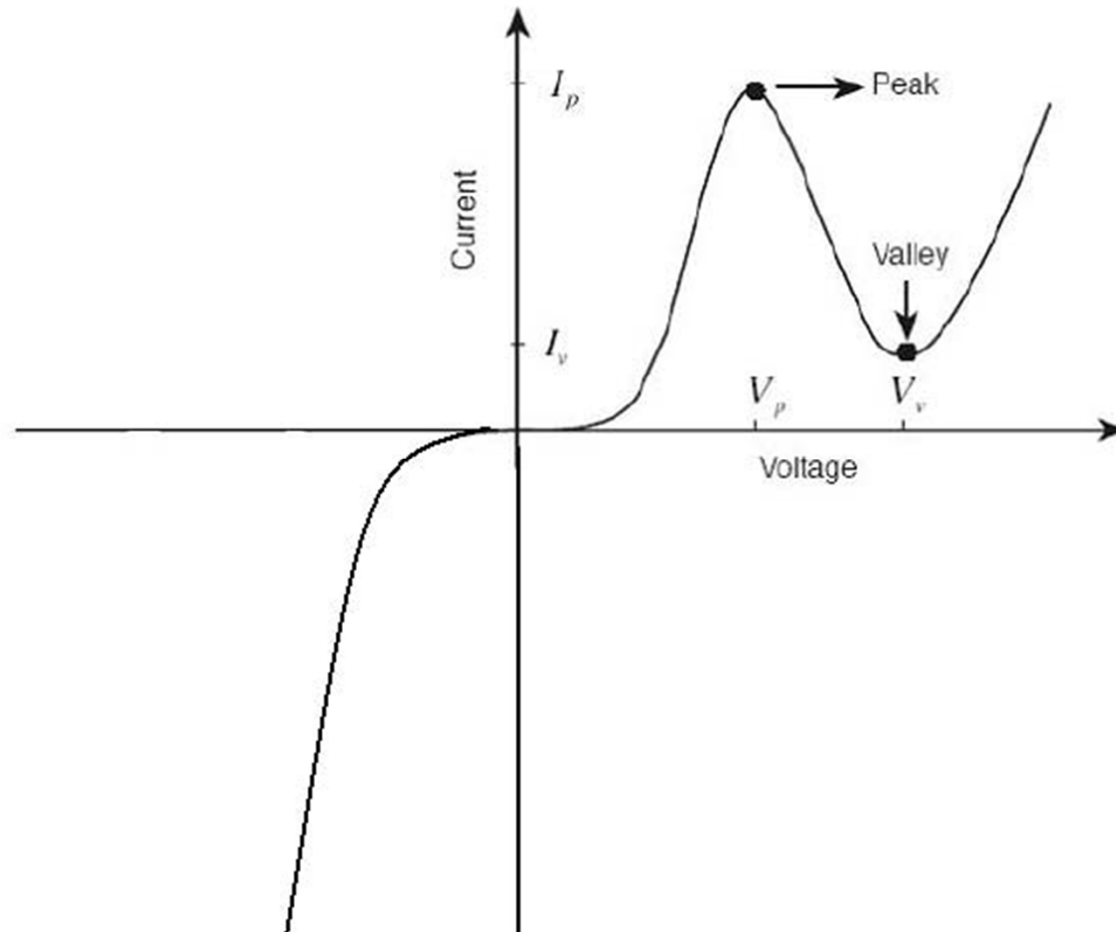
- ▣ Esaki Diodes
 - ▣ Resonant Tunnel Diodes
 - ▣ Si/Si-Ge Resonant Interband Tunnel Diodes
 - ▣ Planar Tunnel Diodes
 - ▣ Vertical Silicon Tunnel Diodes
 - ▣ ACP Tunnel Diodes

Tunnel Diode Operation



- Based on the QM principle of tunneling
- In forward bias, electrons tunnel through narrow barrier
- Further biasing leads to negative resistance region
- Traditional TD have a very high leakage current in reverse bias
- Thin depletion region causes high capacitance

Tunnel Diode IV Characteristics

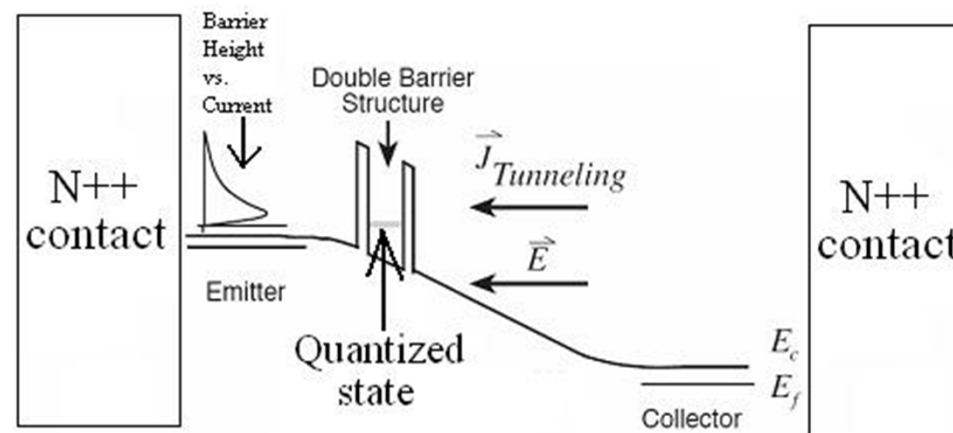


Resonant Tunneling

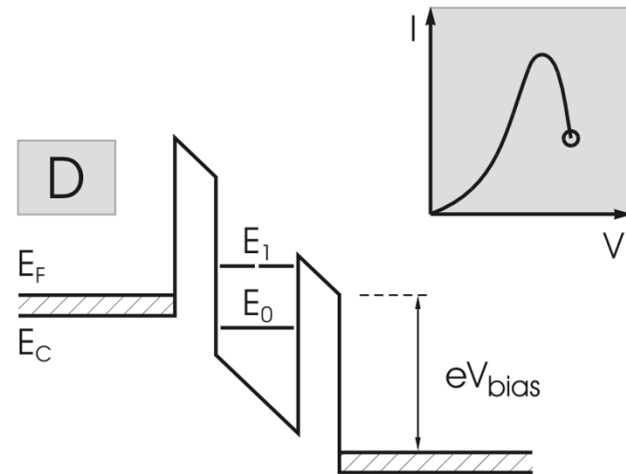
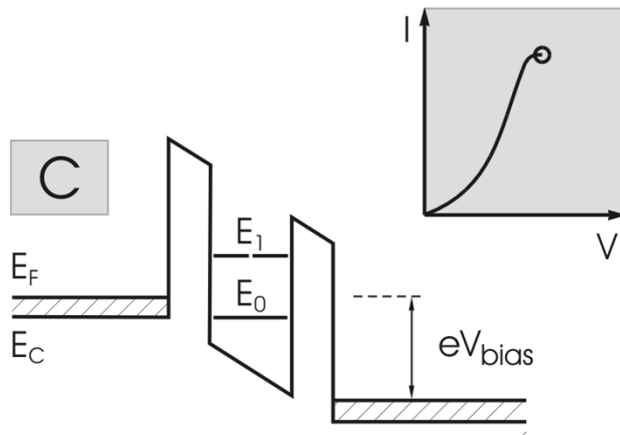
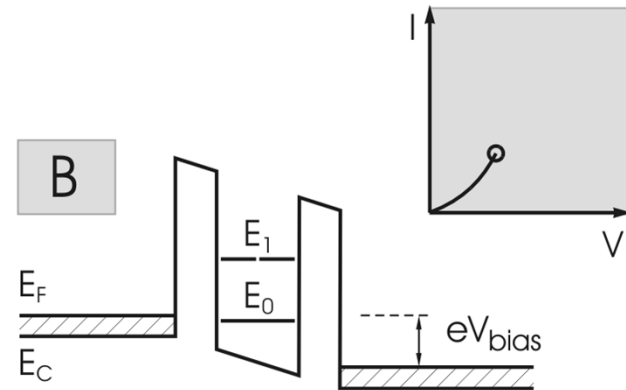
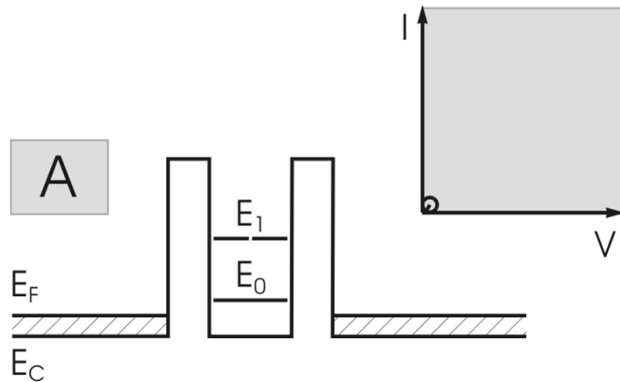
- At certain energies, the transmission coefficient is 1 as if no barriers present
- Transparency only due to resonance at certain quasi states
- The bias allows alignment of emitter with resonant states

Resonant Tunneling Diode

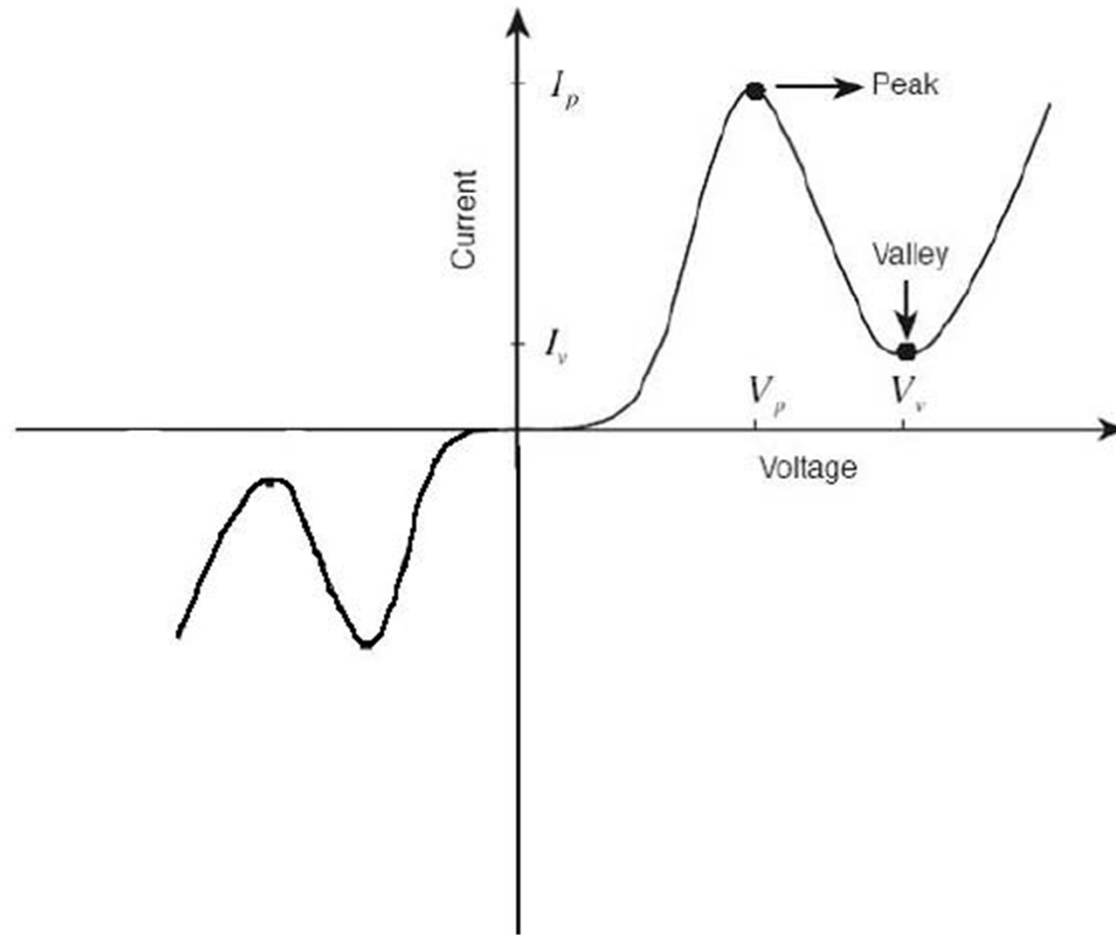
- RTDs use a double barrier quantum well
- The well is surrounded by heavily doped narrow band gap elements
- Well thickness $\sim 5\text{nm}$, barrier layers $\sim 1.5\text{-}5\text{nm}$



RTD Under Bias



RTD IV Characteristics



Comparison



- RTDs have a symmetrical I-V response for both forward and reverse biasing
- High leakage current is eliminated
 - ▣ Good rectifier
- Lower capacitance due to insulating region between wells

Performance



- Output power of RTD is limited
- Can reach frequencies upwards of 2 THz
- 1.2 ps switching speed vs 12ps for Esaki tunnel diode
- A 650 GHz oscillator has been achieved using Schottky Collector RTDs

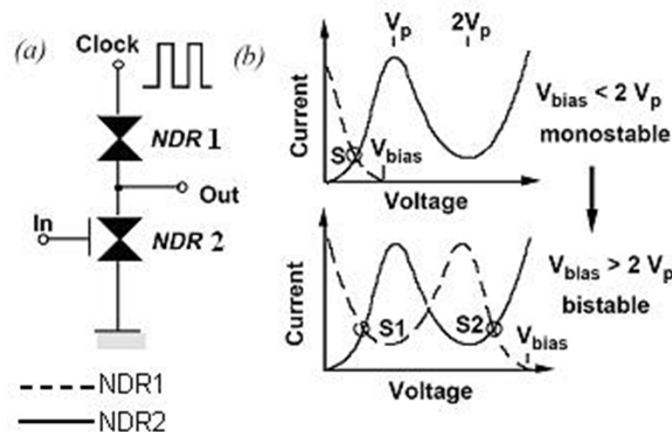
Fabrication



- Usually III-V compound for heterojunctions
- Grown using molecular beam heteroepitaxy
 - ▣ GaAs/AlAs
 - ▣ AlAs/InGaAs or InAlAs/InGaAs
- MOCVD fabrication starting to gain momentum

Applications

- Monostable-bistable transition logic element
 - ▣ Used in high sampling rate applications – imaging/communications
- Oscillators – the negative resistance can be used to compensate for ohmic losses in oscillator circuits
- AtoD converters



Conclusion



- Better fabrications techniques required
 - ▣ Precise barrier thickness control is essential as the device characteristics are dependence on thickness
- Need to improve output power without amplifier
- Researchers still exploring areas of application
- Even after 30 years, still expensive on large scale

References



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